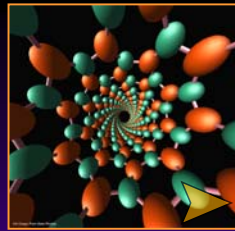
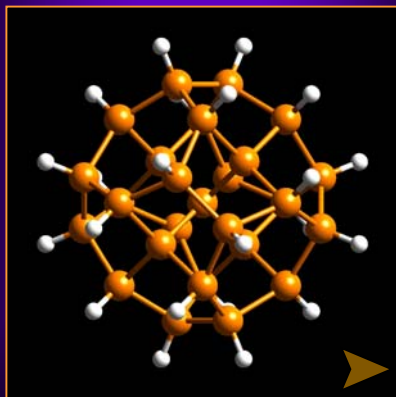




JUNE 1-3, 2005

The Marriott Hotel

SAN FRANCISCO

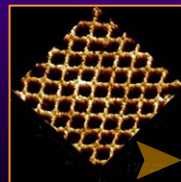


OBJECTIVES

Share overview of
R&D efforts in
Europe, Japan, and
US regions

Identify issues and
challenges

Identify areas for
cooperation and
collaboration



FIRST INTERNATIONAL NANOTECHNOLOGY CONFERENCE ON COMMUNICATION & COOPERATION

2005

*Nanotechnology
on the Road
to
Future
Manufacturing*

Preliminary **AGENDA**

Wednesday June 1, 2005

Conference registration and reception

Thursday June 2, 2005

Regional Overviews by Europe, Japan, and US

Nano-Electronics and Nano-Manufacturing

Speakers to give an update and to identify key issues and challenges for panel discussion

Beyond Planar-Silicon (= 'evolution')

Europe, Japan, US speaker from CWG2

Non-Charge Devices (= 'revolution')

Europe, Japan, US speaker from CWG1

Modeling and System, Design Challenges

Europe, Japan, US speaker from CWG3/CWG4

Panel Discussion

Dinner with guest speaker

Friday June 3, 2005

Update on region specific themes by Europe, Japan, and US

Making Nanotechnology a Reality

Societal Implications of Nanotechnology on ESH,

Updates from all 3 regions (e.g., US by CWG5)

Economical Implications and Nanotechnology Funding

Panel Discussion on Cooperation (INANOI)

Adjourn & Reception